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Study of Two-Layer System Tin / $\text{Ni}_{0.905}\text{W}_{0.095}$ Adoptable for Creating Paramagnetic Substrates with Cubic Texture for 2G HTS Superconductors

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Abstract- The influence of deposition conditions on the morphology and structure of the two-layer system $\text{TiN} / \text{Ni}_{0.905}\text{W}_{0.095}$ were studied. The effect of concurrent formation of cube texture both in substrate based on paramagnetic alloy $\text{Ni}_{0.905}\text{W}_{0.095}$ and TiN coating was detected by means of x-ray diffraction analysis. Composition $\text{TiN} / \text{Ni}_{0.905}\text{W}_{0.095}$ may be used as a substrate in the conductive architecture of 2G HTS to improve its critical current density.

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I. INTRODUCTION

Research in the field of high-temperature superconductors of the second generation (2G HTS) based on YBCO textured films is of particular interest because it opens up new perspectives for creating coated conductors, which could operate in high magnetic fields at temperature of liquid nitrogen (77.4 K). [1 – 6]. First off all this refers to the transfer of electric current over long distances (in particular from the NPP to the consumer), the creation of powerful magnetic fields, etc [7, 8]. As known the architecture of 2G HTS [9] with crucial current density above $j_c \sim 10^6 \text{ A/cm}^2$ at liquid nitrogen temperature should consist of three main components [10 – 13]:

1. Metallic substrate (thin flexible tape mostly of $\text{Ni} - \text{W}$ alloys with different compositions);
2. Buffer layer/layers (oxides, nitrides, in particular TiN as seed layer);
3. Quasi monocrystalline film of high temperature superconductor $\text{YBa}_2\text{Cu}_3\text{O}_{7-\delta}$ ($T_c \sim 92 \text{ K}$ [14]) with strongly reduced fraction of high angle grain boundaries.

Fabrication of high- j_c , biaxially aligned HTS films can be achieved due to epitaxial growth on rolling-assisted biaxially-textured substrates (RABiTS) [11, 15 - 18]. The texture (100)[100] of the metallic substrate is conferred to the superconductor by deposition of

intermediate layers which serve as a chemical and a structural buffers [19]. The presence of a conductive layer acting as an electric shunt to prevent the effect of thermal destruction of superconductor in the case of over-current opens up prospects for use of titanium nitride as the main seed buffer layer in the complex architecture of 2G HTS [20 – 22].

Moreover metallic substrate must be in paramagnetic state at low temperatures to reduce losses during ac current transport [23 - 25]. The property of paramagnetism is provided by increasing the concentration of tungsten in the $\text{Ni}_{(1-x)}\text{W}_x$ alloy to $x \sim 0.095$ [26, 27]. However, it hinders the formation of cube texture (100)[100] due to decreasing of stacking fault energy E_s of cold-rolled alloy. The E_{sf} decreases with increasing the content of alloying element in the alloy [28].

The main aim of this work is to find new ways to control properties of paramagnetic substrates based on $\text{Ni}_{0.905}\text{W}_{0.095}$ alloy for the creating of high-temperature superconductors with high current-carrying capacity (2G HTS).

The following research program was implemented:

1. Experimental study of the effect of nitrogen pressure during titanium evaporation on the structural features of both components of the two-layer system $\text{TiN} / \text{Ni}_{0.905}\text{W}_{0.095}$.
2. Experimental study of the influence of TiN deposition time on the structural features of the components of the $\text{TiN} / \text{Ni}_{0.905}\text{W}_{0.095}$ system at the optimal value of nitrogen pressure.
3. Experimental study of the influence of TiN deposition geometry on the structural features of both components of the $\text{TiN} / \text{Ni}_{0.905}\text{W}_{0.095}$ system.

Development of new ways to control the structure and properties of materials based on paramagnetic Ni-W alloys with TiN coating.

II. MATERIALS AND METHODS

Preparation of substrates was carried out according to the scheme which includes following steps [29, 30]: 1) synthesis of paramagnetic alloy $\text{Ni}_{0.905}\text{W}_{0.095}$; 2) thin-layer tape production; 3) high-temperature

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treatment of NiW tapes; 4) deposition of titanium nitride on the surface of NiW tape; 5) XRD analysis of obtained samples.

The initial materials for obtaining the Ni – W alloys were Ni and W powders with 99.98 – 99.99 % purity (by metallic impurities). The following methods were used for the purification from gaseous impurities (the main impurity is oxygen represented as nickel and tungsten oxides): 1) the heat treatment at temperatures $\sim 850^\circ\text{C}$ for purification of Ni powder; 2) for the refinement of W powder was applied the high-temperature treatment ($1000 - 1200^\circ\text{C}$) in reducing $\text{Ar} + 4\% \text{H}_2$ gaseous mixture flow. The paramagnetic alloy was synthesized by means of powder metallurgy in deep vacuum ($p \sim 10^{-6}$ Torr) at $T = 1200^\circ\text{C}$ during $t = 4$ hours.

Obtained ingots were rolled up to $50 - 100 \mu\text{m}$ at room temperatures to perform metallic tapes. The total degree of cold-rolling deformation was about 95%. The resulting operation during the tape production was high-temperature annealing at $T = 1150^\circ\text{C}$ during $t = 2$ hours.

Thin layers of titanium nitride (TiN) on the surface of Ni - 9.5 at% W tapes were obtained by the method of ion-plasma deposition[31]. Specific parameters of the TiN buffer layer deposition varied within the following ranges: negative substrate potential $U = 50 - 300 \text{ V}$; arc current $I = 80 \text{ A}$; temperature of substrate $t_s \sim 450^\circ\text{C}$; nitrogen pressure in chamber $p_N = 1.2 - 6.2 \cdot 10^{-2}$ Torr; deposition time $t_{\text{TiN}} = 0 - 900 \text{ s}$.

XRD analysis (Cu K α radiation) was carried out to solve the following tasks: determination of the phase composition of the system components both the substrate $\text{Ni}_{0.905}\text{W}_{0.095}$ and coating TiN; determination of lattice parameters; analysis of the texture of the substrate and the coating [31]; determination of the TiN coating thickness [32-34].

The method of determination the TiN-layer thickness is based on X-ray absorption. The intensity of the beam reflected from crystal plane ($h k l$) of a sample with the coating thickness h is as follows:

$$I_{hkl}(h) = I_{hkl}(0) \cdot \exp(-2h \cdot \mu_{\text{TiN}} / \cos(\theta)) \quad (1)$$

$I_{hkl}(h)$ – the intensity of the beam reflected from the substrate with coating;

$I_{hkl}(0)$ – the intensity of the beam reflected from the substrate without coating;

h – coating layer thickness;

μ_{TiN} – the linear absorption coefficient of the coating material;

θ – the Bragg angle.

Equation (1) and mathematical modeling of the relative intensity of some X-ray interferences, in our case - the cubic plane ($h 0 0$) of the Ni - W substrate, makes it possible to determine the coating thickness h_{TiN} within accuracy of about 10%.

III. RESULTS

In the present study the TiN coating was deposited on the front ("face") and the back ("shadow") side i. e out of line of sight of the cathode beam of the $\text{Ni}_{0.905}\text{W}_{0.095}$ substrates. Two series of experiments were carried out:

- TiN deposition at constant time $t_{\text{TiN}} = 3 \text{ min}$ in a wide range of pressures of nitrogen $p_N = 1.2 - 6.2 \cdot 10^{-2}$ Torr.
- The deposition of TiN at constant (optimal) N_2 pressure of nitrogen at different times $t_{\text{TiN}} = 1 - 3 \text{ min}$.

Fig. 1 and Fig. 2 present a set of diffraction patterns of the system TiN/ $\text{Ni}_{0.905}\text{W}_{0.095}$ for the experimental series at different pressures for both face and shadow deposition geometries. There are two systems of diffraction lines, which belong to the FCC lattice of $\text{Ni}_{0.905}\text{W}_{0.095}$ alloy and TiN lattice of type NaCl. As the pressure of nitrogen growths, textures of the substrate and coating exhibit variations.

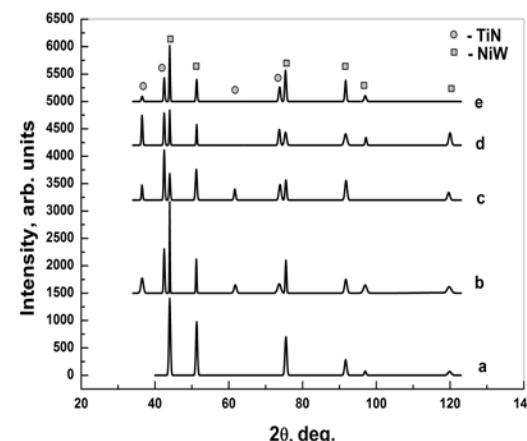


Fig. 1: Set of diffraction patterns of the system TiN / $\text{Ni}_{0.905}\text{W}_{0.095}$ for the experimental series at different pressures ("Shadow"): a) 0; b) 1.2, c) 1.8, d) 2.8, e) $3.8 \cdot 10^{-2}$ Torr.

It is natural that the increase in p_N leads to growth of the intensity of the diffraction lines of TiN, but at the same time there is a tendency to redistribute the intensities of the diffraction lines in the subsystem of $\text{Ni}_{0.905}\text{W}_{0.095}$

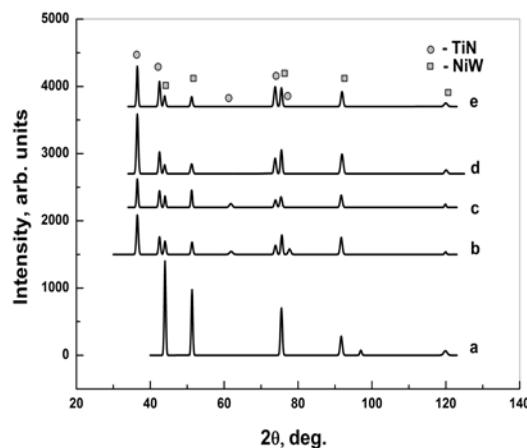


Fig. 2: Set of diffraction patterns of the system TiN / $\text{Ni}_{0.905}\text{W}_{0.095}$ for the experimental series at different pressures ("face"): a) 0; b) 1.2, c) 1.8, d) 2.8, e) 3.8×10^{-2} Torr.

The Fig. 3 clearly shows considerable growth of intensity from Ni-W "cubic" plane $I_{(200)}$ at $p_N \sim 1.8 \cdot 10^{-2}$ Torr, indicating the sharpening of cube texture of metallic component. The ratio of the cubic $I_{(200)}$ and diagonal $I_{(220)}$ diffraction lines intensity was chosen as a "texture parameter".

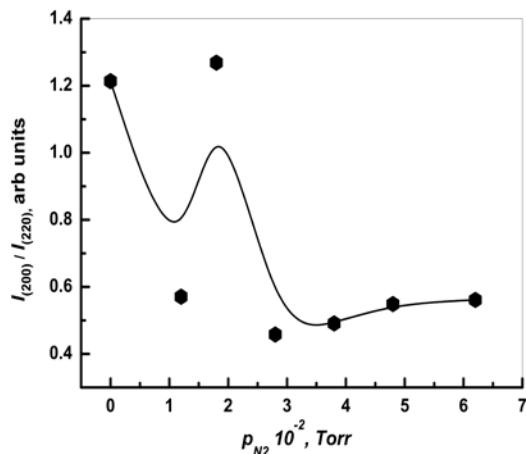


Fig. 3: Values of the ratio $I_{(200)} / I_{(220)}$ of the $\text{Ni}_{0.905}\text{W}_{0.095}$ substrate after TiN deposition

The Fig. 4 shows dependences of TiN lattice constant a_{TiN} on the pressure of N_2 for different coating deposition geometries.

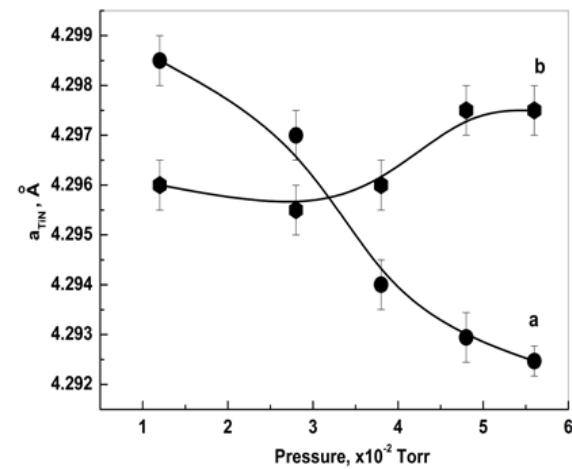


Fig. 4: The lattice parameters change of the TiN coating deposited onto the both sides of the $\text{Ni}_{0.905}\text{W}_{0.095}$ substrate at different pressures of nitrogen depending on the coating geometry: a) face; b) shadow.

As can be seen, in the case of "shadow" geometry, the curve a is weakly dependent on the p_N , while for "face" curve b decreases monotonically in the whole range of nitrogen pressures. Dynamics of variation of the TiN lattice parameter during crystalline phase formation in the coating can be associated with the change in the flux densities of titanium atoms and atoms of nitrogen depending on the coating geometry.

The above data (see. Fig. 1 - 4) give reason to believe that at pressures $p_N \sim 1.8 \cdot 10^{-2}$ Torr there are implemented the most favorable conditions for the formation of cube texture of substrate in TiN / $\text{Ni}_{0.905}\text{W}_{0.095}$ system. The evolution of diffraction pattern depending on the TiN deposition time at optimized $p_N = 1.8 \cdot 10^{-2}$ Torr = const is plotted in the Fig. 5.

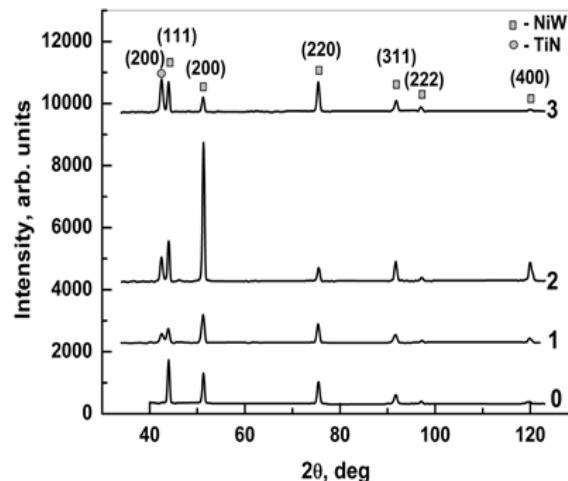


Fig. 5: XRD patterns of $\text{Ni}_{0.905}\text{W}_{0.095}$ alloy tapes with TiN coating ("Face") at $p_N = 1.8 \cdot 10^{-2}$ Torr in the range of 0 - 3 min (from the bottom up)

As the deposition time τ_{TiN} increases up to 2 min, in other words as the coating thickness growths, the relative intensity of (h 0 0) type diffraction lines increases, while the intensities of reflections from the diagonal (h k 0) and other FCC lattice planes decreases. Such behavior of the evolution of diffraction pattern indicates qualitatively substantial intensification of degree of the cubic texture component in $\text{Ni}_{0.905}\text{W}_{0.095}$ paramagnetic alloy tape. According to Fig. 6, that shows diffraction patterns of TiN / NiW systems obtained at different geometry of TiN deposition, mentioned above effect of texture enhancing is more apparent for the "face" coating geometry.

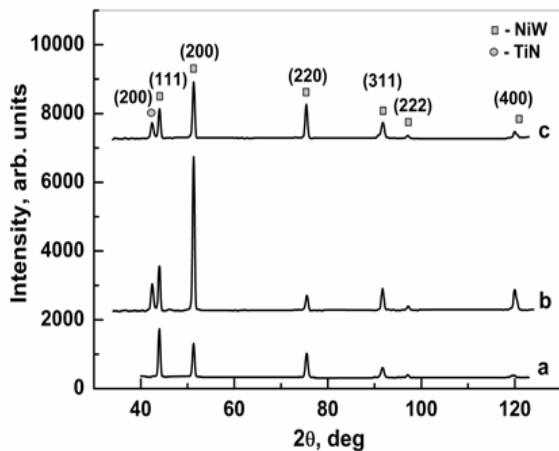


Fig. 6: XRD patterns of $\text{Ni}_{0.905}\text{W}_{0.095}$ alloy tapes with TiN coating ("Face") at $p_N = 1.8 \cdot 10^{-2}$ Torr in the range of 0 – 3 min (from the bottom up). XRD patterns of $\text{Ni}_{0.905}\text{W}_{0.095}$ alloy tapes with TiN coating obtained at optimized conditions at different coating geometry a) Original sample, b) Face, c) Shadow.

The Fig. 7 shows the dependency of texture parameter for $\text{Ni}_{0.905}\text{W}_{0.095}$ versus TiN coating deposition time

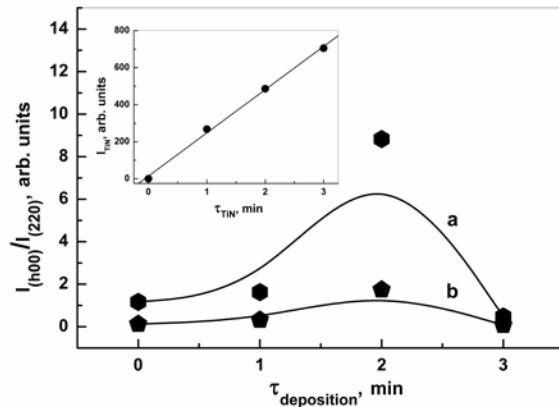


Fig. 7: Dependency of $I_{(h00)} / I_{(220)}$ ratio from $\text{Ni}_{0.905}\text{W}_{0.095}$ substrate on deposition time. Inset: Dependency $I_{(200)}$ for titanium nitride coating

As can be seen it exhibits strong maximum at $\tau_{\text{TiN}} = 2$ min that corresponds to $h_{\text{TiN}} \sim 1 \mu\text{m}$. Process of cubic texture formation is also observed in the coating layer of TiN. This is proved by the presence of only $(200)_{\text{TiN}}$ diffraction line, which belong to cubic plane of the TiN lattice. The inset in the Fig 7 indicates that $I_{(200)}$ from TiN monotonically increases in the whole range of τ_{TiN} .

In order to determine fine variations of texture in the TiN / $\text{Ni}_{0.905}\text{W}_{0.095}$ system the algorithm of circular diagrams was used as a supplementation to the classical ways. This method is based on the construction and analysis of diagrams of the angular distribution of the intensity from crystallographic planes. In order to study the density of normals to (h k l) planes in various directions, a sample need to be rotated by angle ϕ about the normal to its surface.

As a criterion for the validity of the initial hypothesis regarding the realization of perfect cubic texture was chosen the known statistical method χ^2 . To calculate it $n = 23$ degrees of freedom were considered. Of course in the case of forming an ideal cubic texture, the value of "Chi - square" tends to be zero.

By way of illustration the Fig. 8 shows circular diagram from plane of type (h 0 0) for TiN coating at $\tau = 2$ min, where texture effects at which texture effects are most pronounced. The Fig. 9 shows circular diagrams from (2 0 0) plane related to $\text{Ni}_{0.905}\text{W}_{0.095}$ subsystem before (Fig. 9a) and after coating (Fig. 9b) at optimized parameters:

$$h_{\text{TiN}} = 1 \mu\text{m}, p_N = 1.8 \cdot 10^{-2} \text{ Torr.}$$

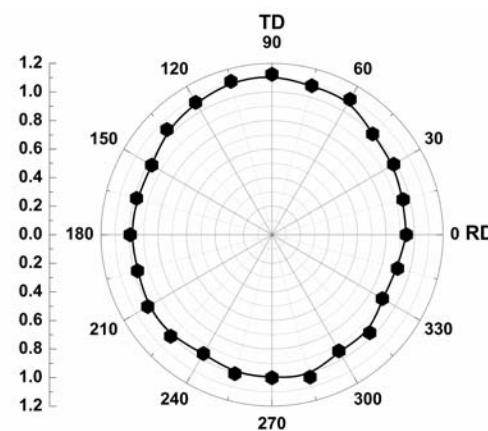


Fig. 8: Circular diagram of (2 0 0) plane for TiN coating layer

It is worth to mention that for crystals belonging to cubic symmetry, the polar absorption tensor does not depend on the direction. Thus, any change in the intensity of the diffracted beam can be solely attributed to the processes of texture formation occurring in a two-layer system "substrate – coating".

One can see from the graphs above that the deposition of the TiN coating leads to the improvement of the cubic texture ($\chi_{\text{tape}} = 0.11 \rightarrow \chi_{\text{coated}} = 0.07$) in the metal component (Ni-W) of the two-layer system TiN / $\text{Ni}_{0.905}\text{W}_{0.095}$ as well as to formation of strong texture in coating layer ($\chi_{\text{TiN}} = 0.005$).

IV. DISCUSSION

The subject of discussion in this paper is a set of observed effects related to the peculiarities of cubic

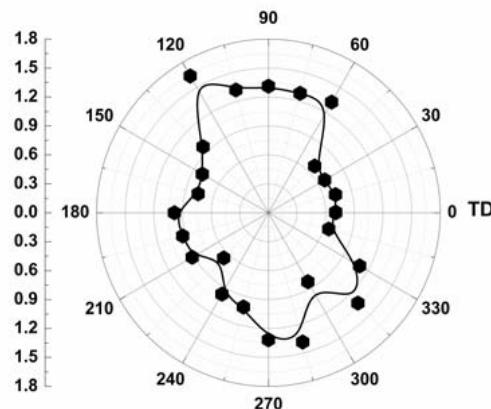


Fig. 9: Circular diagram of (2 0 0) plane from a) original tape based on alloy $\text{Ni}_{0.905}\text{W}_{0.095}$ and b) subsystem

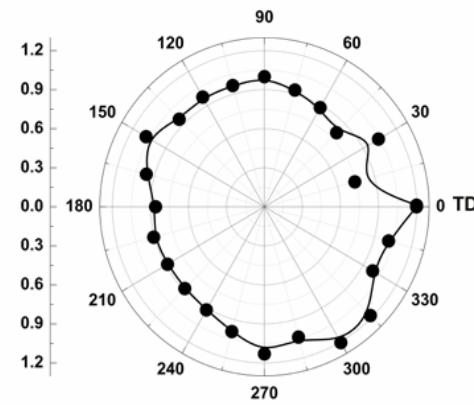
The identified differences in the dependences of the lattice parameters of titanium nitride may be caused by differences in the mechanisms and kinetics of the phase formation of TiN titanium nitride during deposition on different sides of the Ni-W tape. Dependence on the "front" side reflects the increase in the proportion of atoms with low atomic radius. On the "shadow" side the dependence reflects the mechanical reduction of titanium ion flux density due to deposition on the opposite side of the substrate. It is possible that the order of the reaction of the interaction of Ti and N ions may change.

The set of data presented in the figures 5 - 7 clearly indicates the processes of texture formation in substrate based on the paramagnetic alloy $\text{Ni}_{0.905}\text{W}_{0.095}$ under influence of TiN layer. This is clearly supported by the change of shape of intensity distribution from (200)_{NiW} crystal plane as shown in the Fig. 9.

The effect of an anomalous increase in the degree of cubic texture of the substrate, as well as the formation of a biaxial texture in the coating layer, is obviously associated with the process of reorientation of crystallites of both components of the TiN / $\text{Ni}_{0.905}\text{W}_{0.095}$ system under the influence of interfacial stresses arising at the interface of materials with different values of the lattice parameters.

texture formation in the thin-film system TiN / $\text{Ni}_{0.905}\text{W}_{0.095}$ (see Fig. 3 - 9):

1. Qualitative changes in the variation of the crystal lattice parameter dependencies of titanium nitride on the nitrogen pressure by varying the "geometry" of deposition during the experiment.
2. The formation of rather strong cubic texture in metallic layer of the thin-layer system TiN / $\text{Ni}_{0.905}\text{W}_{0.095}$.
3. The formation of quasi mono crystalline structure of TiN buffer layer in the system TiN / $\text{Ni}_{0.905}\text{W}_{0.095}$.



V. CONCLUSION

Ways to control the architecture of two-layer system TiN / $\text{Ni}_{0.905}\text{W}_{0.095}$ based on the change of nitrogen pressure during titanium evaporation, deposition time, and coating geometry were developed.

The conditions for creating two-layer "substrate - coating" compositions are optimized, which provide the possibility of obtaining strong cubic texture in the TiN coating layer deposited on the surface of the tape based on paramagnetic alloy $\text{Ni}_{0.905}\text{W}_{0.095}$.

The main result of the work is the experimental detection of the effect of correlated formation of a cubic texture in both components of the two-layer system TiN / $\text{Ni}_{0.905}\text{W}_{0.095}$, which should provide a significant increase in critical current density of 2G HTS coated conductors.

REFERENCES RÉFÉRENCES REFERENCIAS

1. Bednorz, J.G., and Müller, K.A. (1986). Possible high-T_c superconductivity in the Ba-La-Cu-O system. *Z. Physik B - Condensed Matter* 64, 189-193. <https://doi.org/10.1007/BF01303701>
2. Rupich, M. W., Li, X., Thieme, C., Sathyamurthy, S., Fleshler, S., Tucker, D., Thompson, E., Schreiber, J., Lynch, J., and Buczek, D. (2009). Advances in second generation high temperature superconducting wire manufacturing and R&D at American Superconductor Corporation. *Super-*

conductor Science and Technology, 23: Article 014015. <https://doi.org/10.1088/0953-2048/23/1/014015>

3. Paranthaman, M., Park, C., Cui, X. et al(2000). $YBa_2Cu_3O_7-y$ -coated conductors with high engineering current density. Journal of Materials Research15,2647–2652. <https://doi.org/10.1557/JMR.2000.0379>
4. Rupich, M. W., Schoop U., Verebelyi D.T., Thieme C, Zhang W. Li X., Koden kandath T., Nguyen, N., Siegael E., Buczek D., Lynch J., Jowett M., Thompson E., Wang J. S., Scudiere J., Malozemoff A.P., Li Q., Annavarapu S., Cui S., Fritzemeier L., Aldrich B., Craven C., Niu F., Schwall R., Goyal A., and Paranthaman M (2003). YBCO coated conductors by an MOD/RABiTS/spl trade/ process. *IEEE Transactions on Applied Superconductivity*, 13,2, 2458-2461. Doi: 10.1109/TASC.2003.811820.
5. Larbalestier, D., Gurevich, A., Feldmann, D. et al. (2001). High-Tc superconducting materials for electric power applications. *Nature* 414, 368–377. <https://doi.org/10.1038/35104654>
6. Hassenzahl, W. V. (2001). Superconductivity, an enabling technology for 21st century power systems? *IEEE Transactions on Applied Superconductivity*, 11, 1, 1447-1453. Doi: 10.1109/77.920045
7. Wilson, M. *Superconducting Magnets* (Clarendon, Oxford, 1983).
8. Pyon, T. and Gregory, E. (2001). Nb₃Sn conductors for high energy physics and fusion applications. *IEEE Trans. Appl. Supercond.* 11, 3688–3691. DOI: 10.1109/77.919865.
9. Shiohara, Y., Taneda, T & Yoshizumi, M. (2012). Overview of Materials and Power Applications of Coated Conductirs Project. *Jpn. J. Appl. Phys.* 51, Article: 010007. <https://doi.org/10.1143/JJAP.51.010007>.
10. Malozemoff, A. P., Annavarapu, S., Fritzemeier, L., Li Q, Prunier, V., Rupich, M., Thieme, C., Zhang, W., Goyal, A., and Paranthaman, M.(2000). Low-cost YBCO coated conductor technology. *Supercond. Sci. Technol.* 13, 473–476. <https://doi.org/10.1088/0953-2048/13/5/308>
11. Goyal A. (2005) Epitaxial Superconductors on Rolling-Assisted-Biaxially-Textured-Substrates (RABiTS). In: Goyal A. (eds) *Second-Generation HTS Conductors*. Springer, Boston, MA. https://doi.org/10.1007/0-387-25839-6_2
12. Specht, E. D., Goyal1, A., Lee1, D. F., List,F. A., Kroeger, D. M., Paranthaman, M., Williams R. K. and Christen, D. K. (1998). Cube-textured nickel substrates for high-temperature superconductors. *Supercond. Sci. Technol.* 11 945. <https://doi.org/10.1088/0953-2048/11/10/009>
13. Paranthaman,M., Goyal, A.,List,F. A.,Specht, E. D., Lee, D. F, Martin,P. M., He, Q.,Christen,D. K., Norton, D. P., Budai, J. D., and Kroeger, D. M. (1997). Growth of biaxially textured buffer layers on rolled-Ni substrates by electron beam evaporation. *Physica C: Superconductivity*, 275, 3 – 4, 266272. [https://doi.org/10.1016/S0921-4534\(96\)00713-7](https://doi.org/10.1016/S0921-4534(96)00713-7).
14. Wu, M. K. et al(1987). Superconductivity at 93 K in an new mixed-phase Y-Ba-Cu-O compound system at ambient pressure. *Phys. Rev. Lett.* 58, 908–912.<https://doi.org/10.1103/PhysRevLett.58.908>
15. Eickemeyer, J., Selbmann, D., Hühne, R., Wendrock, H., Hänsch, J., Güth, A., Schulz, L., and Holzapfel, B. (2007). Elongated grains in textured substrate tapes and their effect on transport currents in superconductor layers. *Appl. Phys. Lett.* 90, Article: 012510. <https://doi.org/10.1063/1.2429905>
16. Norton, D. P., Goyal, A., Budai, J. D., Christen, D. K., Kroeger, D. M., Specht, E. D., He, Q., Saffian, B., Paranthaman, M., Klabunde, C. E., Lee, D. F., Sales, B. C., and List F. A.(1996). Epitaxial $YBa_2Cu_3O_7$ on Biaxially Textured Nickel (001): An Approach to Superconducting Tapes with High Critical Current Density. *Science* 274, 5288, 755-757. DOI: 10.1126/science.274.5288.755
17. Iijima, Y., Onabe, K., Futaki, N., Tanabe, N., Sadakata, .N., Kohno O., and Ikeno Y. (1993). Structural and transport properties of biaxially aligned $YBa_2Cu_3O_7x$ films on polycrystalline Ni-based alloy with ion-beam-modified buffer layers. *Journal of Applied Physics* 74, 1905. <https://doi.org/10.1063/1.354801>
18. Goyal, A., Norton, D. P., Budai, J. D., Paranthaman, M., Specht, E. D., Kroeger, D. M., Christen, D. K., He, Q., Saffian, B., List, F. A., Lee, D. F., Martin, P. M. Klabunde, C. E., Hartfield, E., and Sikka V. K. (1996) High critical current density superconducting tapes by epitaxial deposition of $YBa_2Cu_3O_x$ thick films on biaxially textured metals. *Appl. Phys. Lett.* 69, 1795. <https://doi.org/10.1063/1.117489>
19. Hühne, R., Selbmann, D., Eickemeyer, J., Hänsch, J., and Holzapfel, B. (2006). Preparation of buffer layer architectures for $YBa_2Cu_3O_7$ coated conductors based on surface oxidized Ni tapes. *Supercond. Sci. Technol.* 19, 169. <https://doi.org/10.1088/0953-2048/19/2/003>
20. Hühne, R, Fähler, S., and Holzapfel, B. (2004). Thin biaxially textured TiN films on amorphous substrates prepared by ion-beam assisted pulsed laser deposition. *Appl. Phys. Lett.* 85, 2744. <https://doi.org/10.1063/1.1802385>
21. Gartner, R., Huhne, R., J., Engelmann, Hanisch, J., Kaltfoten, R., Oswald, S., Schultz, L., and Holzapfel, B. (2010). High-Jc YBCO Coated Conductors Based on IBAD-TiN Using Stainless Steel Substrates. *IEEE*

transactions on applied superconductivity 21, 3, 2920-2923 DOI: 10.1109/TASC.2010.2080657

22. Guth, K., Huhne, R., Matias, V., Rowley, J., Thersleff, T., Schultz, L., and Holzapfel, B. (2009). Preparation of conductive buffer architectures based on IBAD-TiN. *IEEE transactions on applied superconductivity* 19, 3, 3447-3450. <https://doi.org/10.1109/TASC.2009.2019249>

23. Thompson, J. R., Goyal, A., Christen, D. K., and Kroeger, D. M. (2002). Ni-Cr textured substrates with reduced ferromagnetism for coated conductor applications. *Physica C: Superconductivity*, 370, 3, 169-176. [https://doi.org/10.1016/S0921-4534\(01\)00937-6](https://doi.org/10.1016/S0921-4534(01)00937-6).

24. Gaitsch, U., Hänisch, J., Hühne, R., Rodig, C., Freudenberger, J., Holzapfel, B., and Schultz, L. (2013). Highly alloyed Ni-W substrates for low AC loss applications. *Superconductor Science and Technology*, 26, 085024 <https://doi.org/10.1088/0953-2048/26/8/085024>

25. Subramanya Sarma, V., Eickemeyer, J., Schultz, L., and Holzapfel, B. (2004). Recrystallisation texture and magnetisation behaviour of some FCC Ni-W alloys. *Scr. Mater.* 50, 953. <https://doi.org/10.1016/j.scriptamat.2004.01.004>

26. Hühne, R., Eickemeyer, J., Sarma, V. S., Güth, A., Thersleff, T., Freudenberger, J., de Haas, O., Weigand, M., Durrell, J. H., and Schultz, L. (2010). Application of textured highly alloyed Ni-W tapes for preparing coated conductor architectures. *Supercond. Sci. Technol.* 23 03401 <https://doi.org/10.1088/0953-2048/23/3/034015>.

27. Derevyanko, V.V., Sungurov, M. S., Sukhareva, T. V., Finkel, V. A., and Shakhov, Yu. N. (2018). Effect of the Composition and Crystal Structure on the Electrophysical Properties of the $Ni_{1-x}W_x$ System at Low Temperatures. *Physics of Solid State*, 60, 10, 1930 – 1934. DOI: 10.1134/S1063783418100062.

28. Mohamed, F. A. (1979). Creep behavior of solid solution alloys. *Materials Science and Engineering*, 38, 1, 73-80. [https://doi.org/10.1016/0025-5416\(79\)90034-X](https://doi.org/10.1016/0025-5416(79)90034-X).

29. Finkel, V. A., Bovda, A. M., Derevyanko, V. V., Leonov, S. A., Sungurov, M. S., Sukhareva, T. V., Khoroshikh, V. M., and Shakhov, Yu. N. (2012). Researches and developments on production of Ni-W alloy based substrates for second generation high-temperature superconductors. *Functional Materials* 19, 1, 109.

30. Finkel, V. A., Derevyanko, V. V., Sungurov, M. S., Sukhareva, T. V., and Shakhov, Yu. N. (2013). Production of textured ribbons based on Ni-W paramagnetic alloys. *Functional Materials* 20, 1, 103. DOI: 10.15407/fm20.01.103

31. Aksenov, I. I., Khoroshikh, V. M., Lomino, N. S., Ovcharenko, V. D., and Zadheprovskij, Yu. A. (1999). Transformation of axial vacuum-arc plasma flows into radial streams and their use in coating deposition. *IEEE trans. Plasma Sci.* 27, 4, 1026-1029.

32. Sungurov, M.S., Derevyanko, V.V., Leonov, S.A. et al. (2014). Substrates with a cubic texture based on paramagnetic Ni-W alloy ribbons with thin TiN coating for second-generation high-temperature superconductors. *Tech. Phys. Lett.* 40, 797-800 <https://doi.org/10.1134/S1063785014090314>.

33. Friedman H., and Birks L. S. (1946) Thickness Measurement of Thin Coatings by X — Ray Absorption. *Review of Scientific Instruments* 17, 99. <http://dx.doi.org/10.1063/1.1770449>

34. Tomov, I., and Vasiliev S. (2007). Thickness Measurement of Thin Textured Films by a Novel X-Ray Diffraction Method Accounting for_Secondary Extinction. *Solid State Phenomena* 130, 43-46. <http://dx.doi.org/10.4028/www.scientific.net/SSP.130.43>

35. Finkel, V. A., Sukhareva, T. V., and Sungurov M. S. (2020). Detecting and determining the nature of an anomalous x-ray optical effect in two-Layer substrate-coating systems. *Low Temperature Physics* 46, 594 <https://doi.org/10.1063/10.0001241>

